Electronic Supplementary Information (ESI)

Bubble-supported engineering of hierarchical CuCo₂S₄ hollow spheres for enhanced electrochemical performance

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Experimental section

1.1 Materials

All the reagents in the experiment were analytical grade and used without any further treatment. $Cu(NO_3)_2 \cdot 3H_2O$, $Co(NO_3)_2 \cdot 6H_2O$, sulfur powder, thiourea and thioacetamide were purchased from J&K Scientific Ltd. Ethylene glycol and isopropyl alcohol were purchased from Real&Lead Chemical Co., Ltd.

1.2 Preparation of CuCo₂S₄

Hierarchical CuCo₂S₄ hollow spheres were prepared by a solvothermal method. At first, 1 mmol of Cu(NO₃)₂·3H₂O, 2 mmol of Co(NO₃) $_2$ ·6H₂O and 4 mmol of thiourea were dissolved in the mixed solution of 40 mL ethylene glycol and 40 mL isopropyl alcohol. The homogeneous pink

mixture was transferred to a 100 mL Teflon-lined autoclave and heated at 180 °C for 12 h. The precipitate was collected by centrifugation and washed with ethanol and dried at 60 °C. The precursors were calcined at 350 °C for 2 h in N₂ to obtain hierarchical CuCo₂S₄ hollow spheres. For comparison, CuCo₂S₄ with different morphologies were also prepared using sulfur powder and thioacetamide instead of thiourea by the same experimental procedure.

1.3 Material characterization

X-ray diffraction (XRD) patterns were recorded on a Bruker D8 (Cu K_a radiation, λ =1.54056 Å). The Raman spectra was recorded on a Renishaw Invia Plus laser Ramanspectrometer (Renishaw, UK), with an excitation laser wavelength of 514 nm. The morphology of samples was studied by scanning electron microscopy (SEM) (Hitachi S4800, Japan) with accelerating voltage of 5.0 kV. Transmission electron microscopy (TEM) characterization was performed on JEM 3100 (JEOL, Japan) operated at 200 kV. X-ray photoelectron spectroscopy (XPS) analyses were conducted with a Physical Electronics PHI5802 instrument using X-rays magnesium anode (monochromatic K_a X-rays at 1253.6 eV) as the source. Cycling voltammetry (CV), galvanostatic charge-discharge (CD) and electrochemical Impedance Spectroscopy (EIS) are performed with CHI660D (Shanghai Chenhua, China) electrochemical workstation.

1.4 Electrochemical measurements

The slurry of the work electrode was prepared by mixing $CuCo_2S_4$, carbon black (Super P) and polytetrafluoroethylene (binder) at a mass ratio of 8:1:1. The mixed slurry was pasted onto Ni foam with 2 mg cm⁻² followed by drying at 80°C under vacuum. Electrochemical properties were evaluated by a three-electrode system with a Pt foil as the counter electrode and a Hg/HgO (SCE) as the reference electrode in an aqueous 6 M KOH electrolyte. The CV curves was measured in a potential range of 0-0.55 V vs Hg/HgO and CD was measured at different current densities in a potential range of 0-0.48 V vs Hg/HgO. EIS measurements were carried out by applying an AC voltage with 5 mV amplitude in a frequency range of $0.1\sim100$ kHz.



Fig. S1 (a) CV curves of the $CuCo_2S_4$ -SP at different scan rates. (b) charge-discharge curves of $CuCo_2S_4$ -SP at different current densities.



Fig. S2 (a) CV curves of the CuCo₂S₄-TAA at different scan rates. (b) charge-discharge curves of CuCo₂S₄-TAA at different current densities.

Sample	Specific capacitance	Capacitance retention	Preparation method	Reference
Mesoporous	736 F g ⁻¹ at	71.7 % (from 2 to	hydrothermal method	1
$NiCo_2S_4$	2 A g ⁻¹	50 A g ⁻¹)	-	
Nanosheets				
Mesoporous	972 F g ⁻¹ at	82.1 % (from 2 to	solvothermal method	2
NiCo ₂ S ₄	2 A g ⁻¹	30 A g ⁻¹)		
nanoparticles				
NiCo ₂ S ₄ ball-	1036 F g ⁻¹ at	68.1 % (from 1 to	two steps	3
in-ball hollow	1 A g ⁻¹	20 A g -1)	solvothermal method	
spheres				
NiCo ₂ S ₄	895.2 F g ⁻¹	65.4 % (from 1 to	sacrificial template	4
hollow prisms	at 1 A g ⁻¹	20 A g ⁻¹)	method	
CoNi ₂ S ₄	972.2 F g ⁻¹	60.1 % (from 1 to 5	solvothermal method	5
nanoparticles	at 2 A g ⁻¹	A g ⁻¹)		
Tube-like	1048 F g ⁻¹ at	50.1 % (from 3 to	hydrothermal	6
NiCo ₂ S ₄	3 A g ⁻¹	10 A g ⁻¹)	method	
Co_2CuS_4	768 F g ⁻¹ at		solvothermal method	7
nanoparticle	1 A g ⁻¹			
Mesoporous	752 F g ⁻¹ at	47.9 % (from 2 to	solvothermal method	8
$CuCo_2S_4$	2 A g ⁻¹	100 A g ⁻¹)		
Hierarchical	1137.5 F g ⁻¹	84.8% (from 2 to 20	buble-supported	This work
$CuCo_2S_4$	at 2 A g ⁻¹ ,	A g ⁻¹)	solvothermal method	
hollow spheres	964.2 F g ⁻¹			
	at 20 A g ⁻¹			

Table S1. Comparison of the specific capacitance and capacitance retention for sulfide spinels with different morphologies.

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